Two-step electrodeposition of Hausmannite sulphur reduced graphene oxide and cobalt-nickel layered double hydroxide heterostructure for high-performance supercapacitor

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SUPPLEMENTARY INFORMATION



Fig. S1: Low resolution SEM micrographs of CN samples synthesized using different number of CV cycles at a scan rate of 5 mV s⁻¹: (a) CN-3, (b) CN-6 and (c) CN-9.



Fig. S2: SEM images of CCBW at: (a) low resolution and (b) high resolution.



Fig S3: TEM image of MO/RGO-S-50@CN.



Fig S4: (a)-(f) shows the elemental mapping of MO/RGO-S-50@CN displaying the distribution of oxygen, manganese, carbon, nickel, sulphur, and cobalt, respectively and (g) shows the percentage composition of the elements within the material.



Fig. S5: The XRD patterns of samples with various RGO-S mass loading.



Fig. S6: Raman images of CN samples synthesized using different number of CV cycles.



Fig. S7: (a) CV for MO/RGO-S-50@CN at 50 mV s⁻¹ using different electrolytes.



Fig. S8: (a) CV, **(b)** GCD, **(c)** specific capacity vs number of CV cycles and **(d)** Nyquist plot (insert is high frequency magnification indicating ESR values) of CN samples synthesized using different number of CV cycles as indicated in the figure: